IAPS Rec'd PCT/PTO 30 DEC 2005

Sheet _1 _ of _1___

Form PTO-1449 (REV. 8-83)		US Dept. of Commerce PATENT & TRADEMARK OFFICE		ATTY Do 126503	OCKET NO.	1	APPLICATION NO. New U.S. National Stage of		
INFORMATION DISCLOSURE STATEMENT						1	CT/FR2004/00	931	
(Use several sheets if necessary)				APPLICANTS Hubert GRANGE et al.					
					FILING DATE December 30, 2005				
U.S. PATENT DOCUMENTS									
EXAMINER INITIAL		DOCUMENT NUMBER	DATE		NAM	1E	CLASS	SUB CLASS	
/AWO/	1	5,750,420	05/12/1998		Bono et al.		*****		
/AWO/	2	6,004,832	12/21/1999		Haller et al.				
/AWO/	3	5,824,608	10/20/1998		Gotoh et al.		Meccecon	Mercent Common	
/AWO/	4	5,489,556	02/06/1996		Li et al.				
	-								
			-	************					

FOREIGN PATENT DOCUMENTS									
		DOCUMENT NUMBER	DATE		COUN	rry	CLASS	SUB CLASS	
/AWO/	5	EP 0 456 029 A1	11/13/1991		Europe				
	-								
							-		
OTHER DOCUMENTS (Including Author, Title, Date, Pertinent Pages, etc.)									
/AWO/	6	Alley et al., "The Effect of Release-Etch Processing on Surface Microstructure Stiction," Solid-State Sensor and Actuator Workshop, 5th Technical Digest, IEEE Hilton, pp. 202-207, 1992							
-									
	-								
							-		
EXAMINER	(AMINER /Allan Olsen/					DATE CONSIDERED 03/31/2007			
Examiner: Initial if citation considered, whether or not citation is in conformance with M.P.E.P. 609; draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.									